

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re the Application of

Group 1795

Steven A. Soper *et al.*

Examiner Lee, Sin J.

Serial No. 10/734,816

Confirmation No. 3513

Filing Date: December 12, 2003

For: Photoresist-Free Micropatterning on Polymer Surfaces (File Soper 0023.1)

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**AMENDMENT AFTER FINAL ACTION**

In response to the final office action dated May 12, 2009, please amend the Claims as shown in the Appendix.

It is believed that no fee is required to submit this paper. However, if a fee should be due, please refer to the Deposit Account Authorization previously filed with this application. If any extension of time is required, please consider this paper a petition for the total extension of time required. See 37 C.F.R. § 1.136(a)(3).

The present amendment should place all Claims in condition for allowance. Consideration of the amendment should require no additional search, nor should it present a substantial burden to the examiner. Thus the amendment is believed to be appropriate for submission "after final."

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